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### **EUROPEAN PATENT APPLICATION**

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(71) Applicant: ELF ATOCHEM NORTH AMERICA, INC. Philadelphia, Pennsylvania 19103-3222 (US)

(72) Inventors:

· Martyak, Nicholas M. Doylestown, PA 18901 (US)

- · Corsentino, John A. Hazlet, NJ 07730 (US)
- · Rohling, Frederik L. 2023 SM Haarlem (NL)
- · Kasper, Marie M. Redbank, NJ 07701 (US)
- (74) Representative: Weisert, Annekäte, Dipl.-Ing. Dr.-Ing. et al Patentanwälte **Kraus Weisert & Partner** Thomas-Wimmer-Ring 15 80539 München (DE)

#### (54)High current density zinc organosulfonate electrogalvanizing process and composition

(57)The inventors disclose a process for reducing high current density edge buildup dendrite formation, edge burn, controlling high current density roughness, grain size, and orientation of a zinc coating obtained from an aqueous zinc acidic electrogalvanic coating bath comprising passing a high density current from a zinc anode in the bath to a metal cathode in the bath for a period of time sufficient to deposit a zinc coating on the cathode. The bath contains greater than about 5g/l of a water soluble zinc organosulfonate. A random or block polyoxyalkylene glycol homopolymer or copolymer based on 2 to about 4 carbon atom alkylene oxides. The inventors employ current densities from about 250 to about 4,000 ASF, and optionally, a sulfonated condensation product of naphthalene and formaldehyde, a boron oxide compound, and a lignin compound. The invention also comprises bath compositions.



## **EUROPEAN SEARCH REPORT**

Application Number EP 97 10 0964

Category	Citation of document with in of relevant pa	ndication, where appropriate, ssages	Relevant to claim	CLASSIFICATION OF APPLICATION (Int.Cl.	
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